

Title (en)

METHOD OF ELIMINATING THE PROTRUSION AND RESISTANCE ORIGINATING FROM THE FLANGES FORMED AT THE INTERIOR SURFACES OF AIR DUCTS

Title (de)

VERFAHREN ZUR BESEITUNG DES ÜBERSTANDES UND WIDERSTANDES INFOLGE VON FLANSCHEN AUF DEN INNENFLÄCHEN VON LUFTKANÄLEN

Title (fr)

PROCÉDÉ D'ÉLIMINATION DE LA SAILLIE ET DE LA RÉSISTANCE VENANT DES BRIDES FORMÉES AU NIVEAU DE SURFACES INTÉRIEURES DE CONDUITES D'AIR

Publication

**EP 2553348 A1 20130206 (EN)**

Application

**EP 10779066 A 20100921**

Priority

- TR 201002529 A 20100401
- TR 2010000182 W 20100921

Abstract (en)

[origin: WO2011123078A1] The invention is the air duct (10) having air duct end parts (11), which are left open, added to each other via using flanges (20), and used in ventilation, pneumatic carrying, filtration etc. systems found in industrial or commercial facilities, and it is characterized in that; said air duct end part (11) comprises an outwards inclined surface (12) with a certain alpha angle. The invention is bringing the level of the interior surface of the air duct body (10) and the level of the interior surface (21) of the flange at the same alignment via configuration of said outwards inclined surface (12) with the purpose of eliminating the protrusion and the resistance originating from the flange (20) formed at the interior surface of the air channels (10).

IPC 8 full level

**F24F 13/02** (2006.01); **F16L 23/14** (2006.01)

CPC (source: EP)

**F16L 23/14** (2013.01); **F24F 13/0209** (2013.01)

Citation (search report)

See references of WO 2011123078A1

Citation (examination)

- US 5103872 A 19920414 - JYH-LONG CHANG [TW]
- DE 202006006139 U1 20060706 - LTA LUFTTECHNISCHE KOMPONENTEN [DE]
- US 4558892 A 19851217 - DAW DAVID E [US], et al

Designated contracting state (EPC)

AL AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HR HU IE IS IT LI LT LU LV MC MK MT NL NO PL PT RO SE SI SK SM TR

DOCDB simple family (publication)

**WO 2011123078 A1 20111006**; EP 2553348 A1 20130206; TR 201002529 A2 20110822

DOCDB simple family (application)

**TR 2010000182 W 20100921**; EP 10779066 A 20100921; TR 201002529 A 20100401